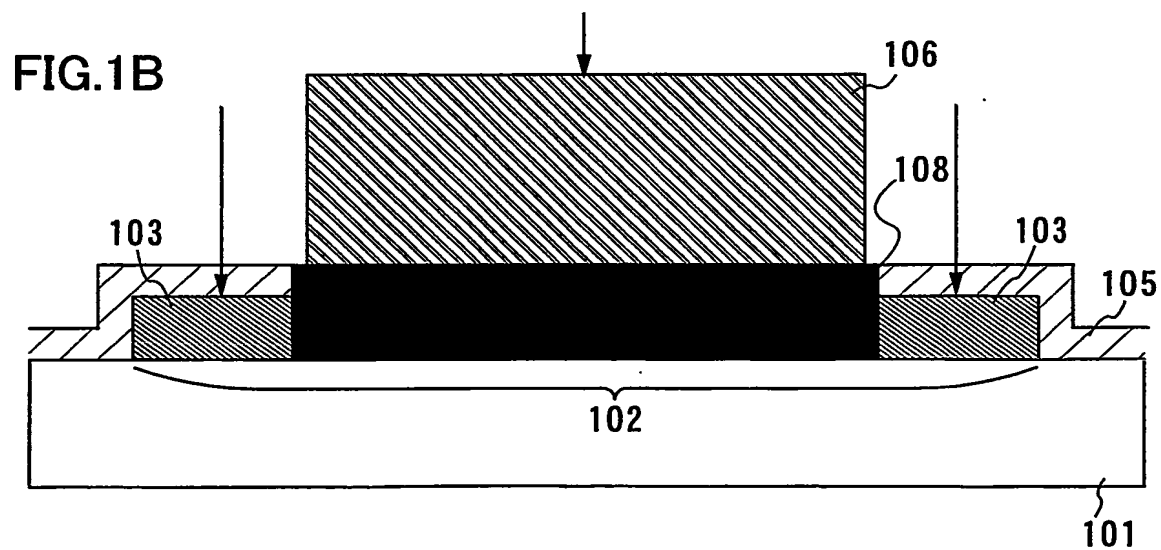
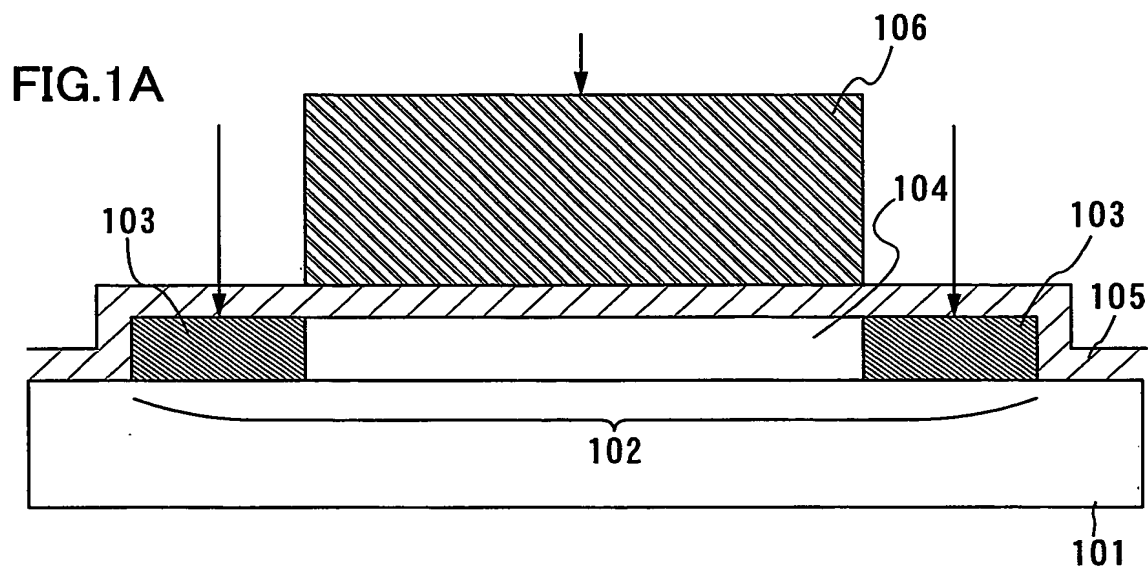


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FIG.2

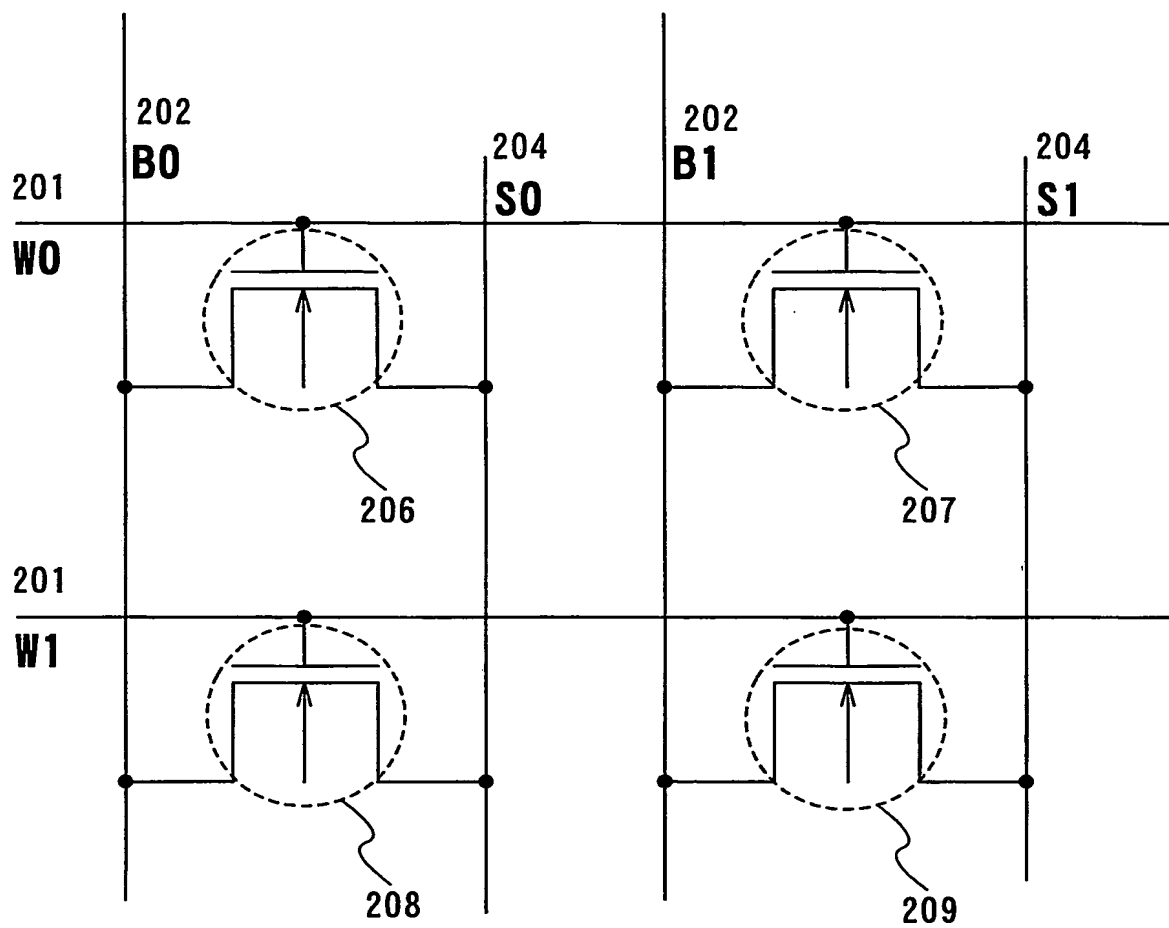


FIG.3A

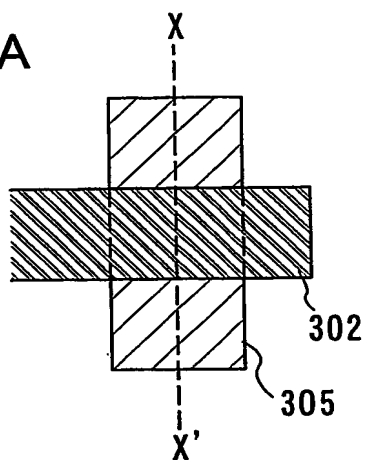


FIG.3B

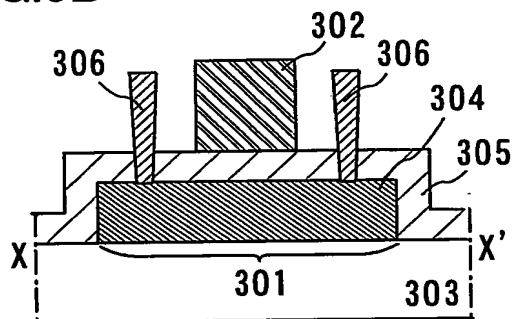


FIG.3C

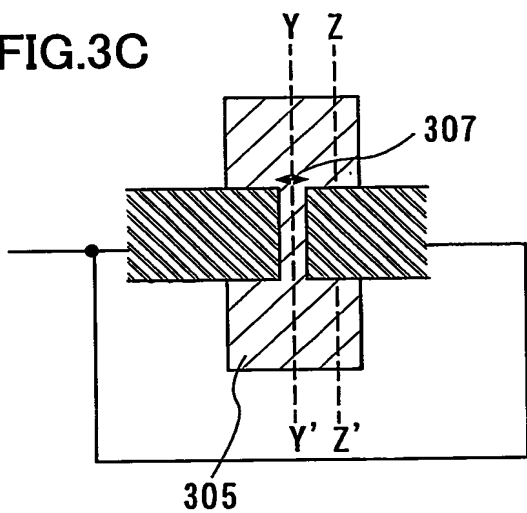


FIG.3D

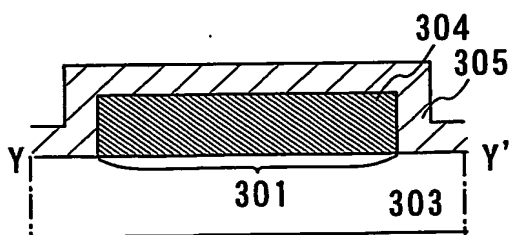
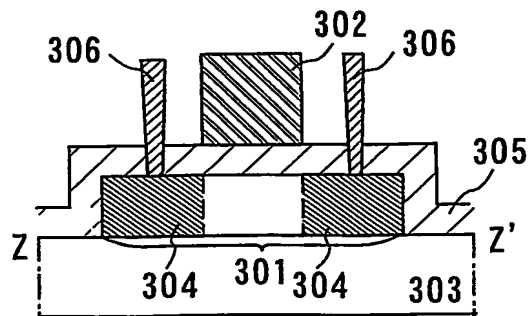
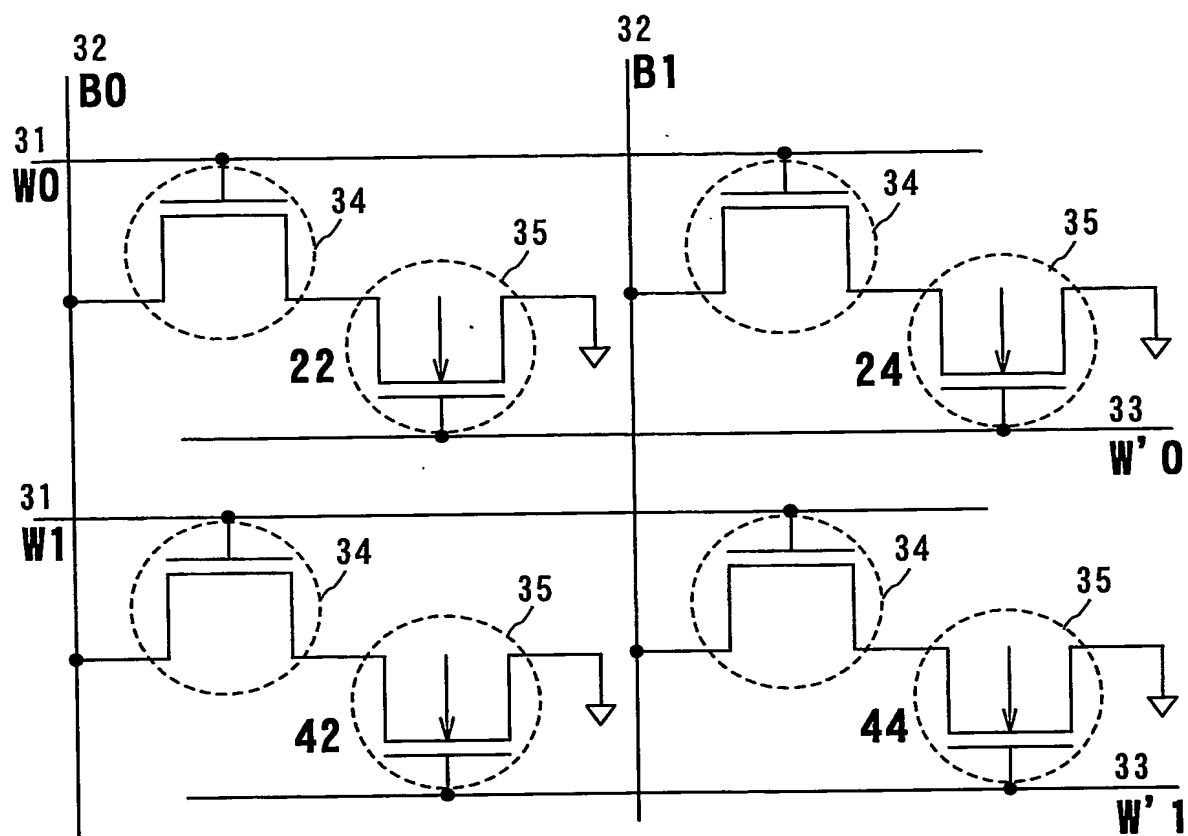


FIG.3E



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FIG.4



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FIG.5A

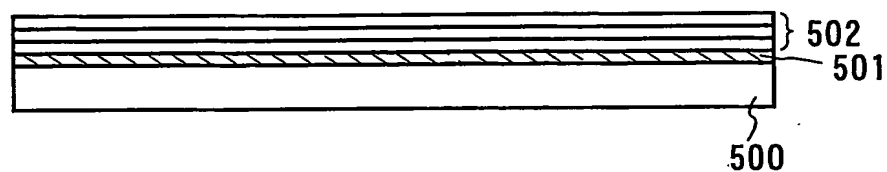


FIG.5B

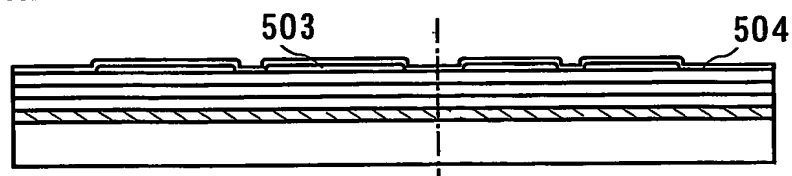


FIG.5C

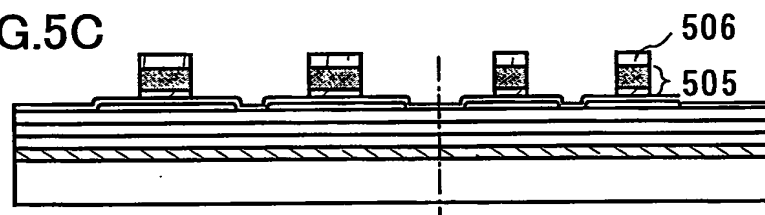


FIG.5D

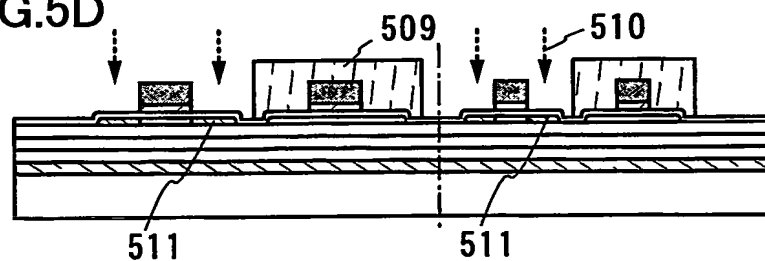


FIG.5E

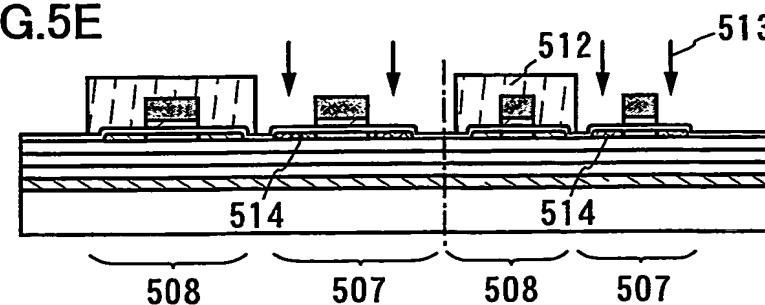


FIG.6A

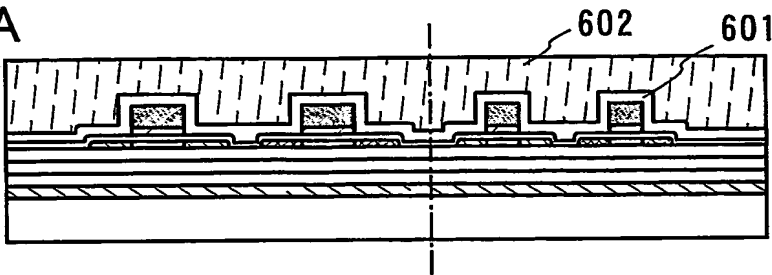


FIG.6B

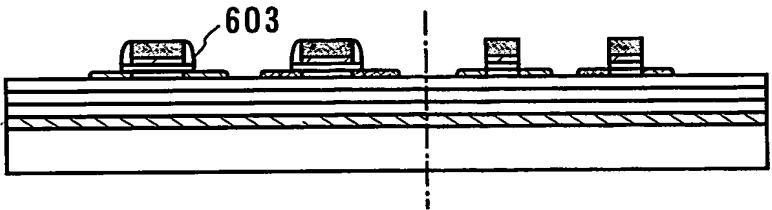


FIG.6C

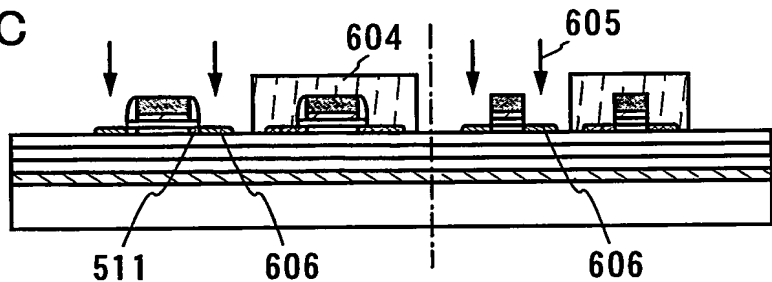


FIG.6D

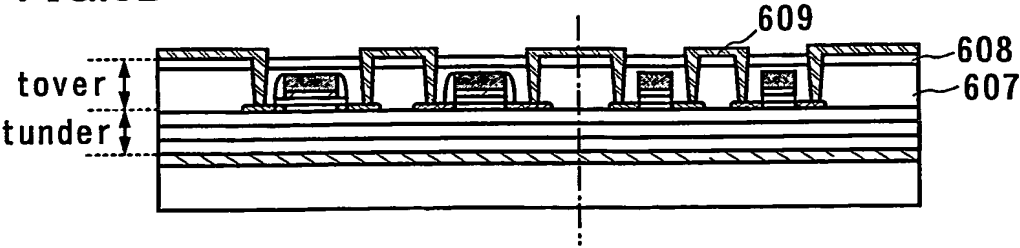


FIG7.A

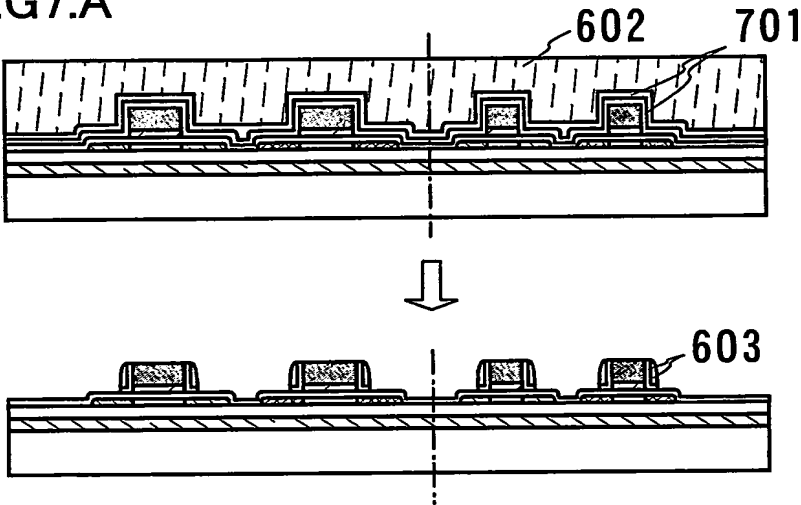


FIG7.B

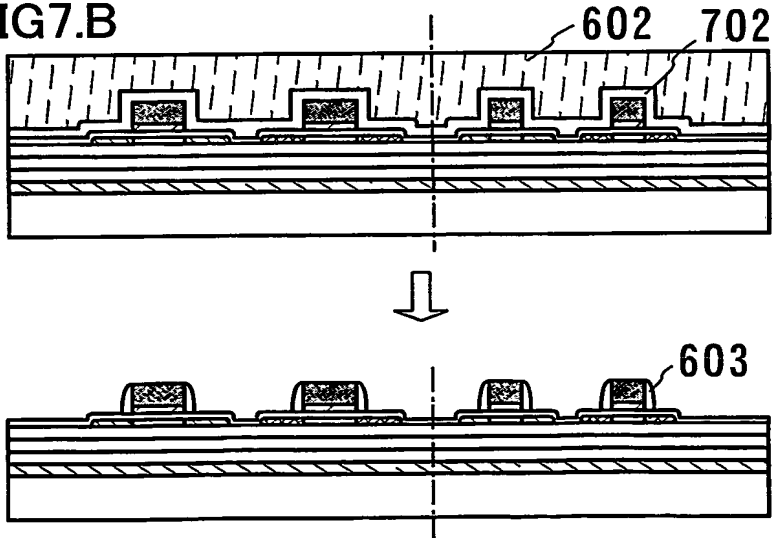


FIG.8A

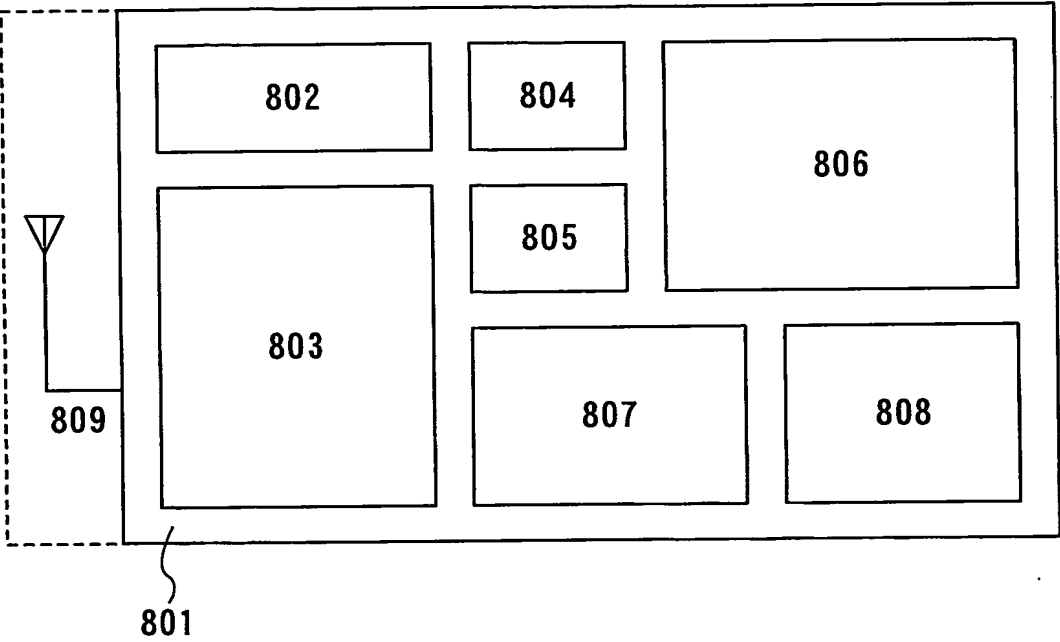
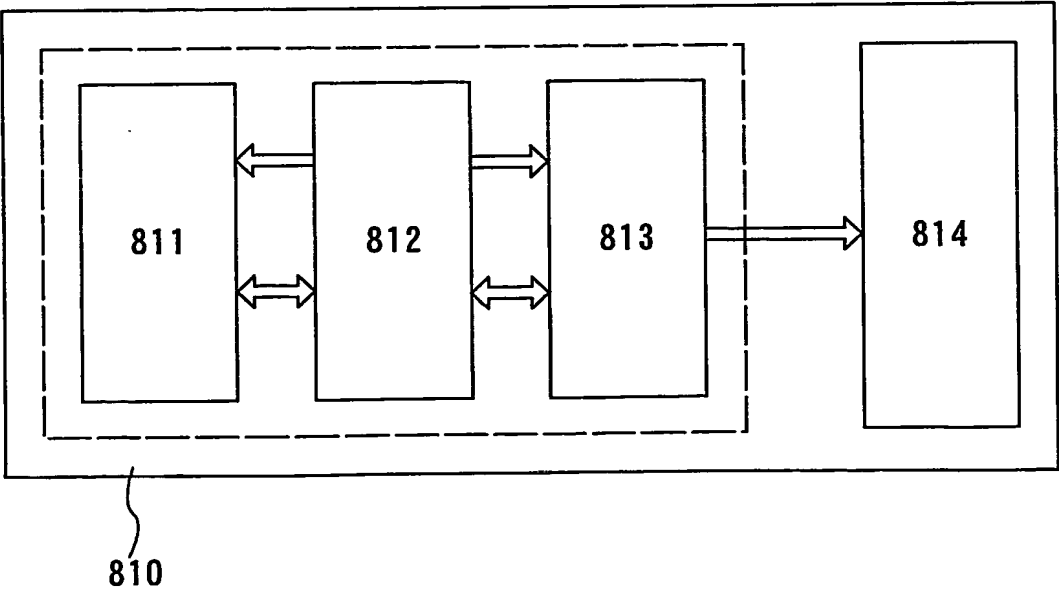


FIG.8B





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FIG.9A

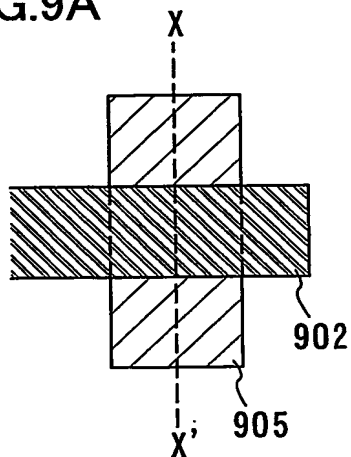


FIG.9B

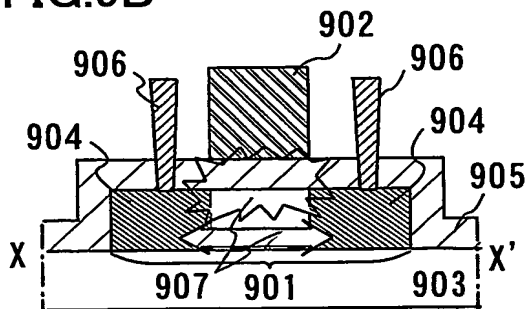


FIG.9C

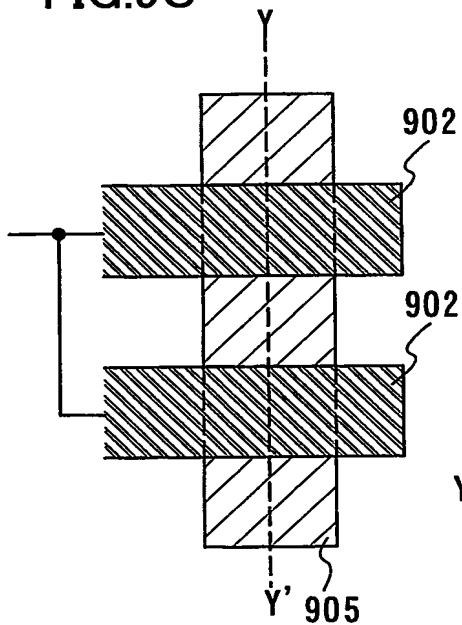


FIG.9D

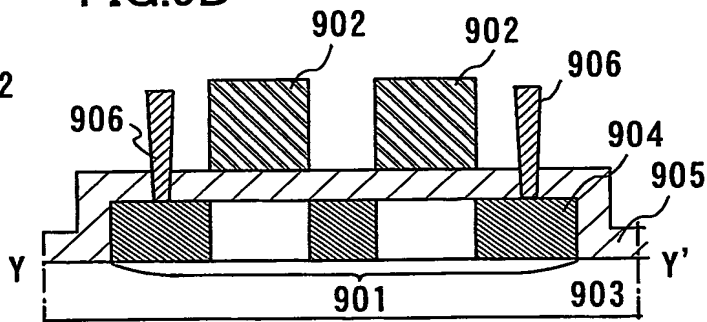


FIG.9E

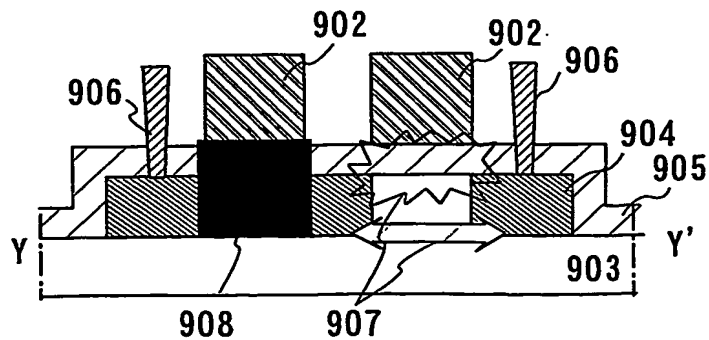


Fig. 10A

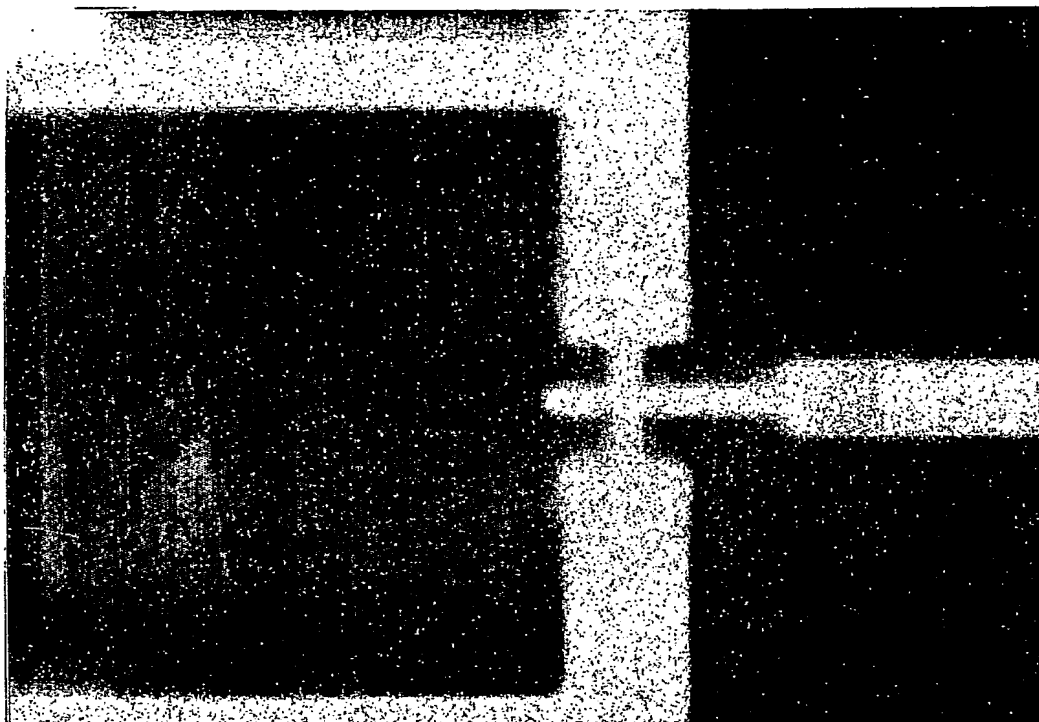
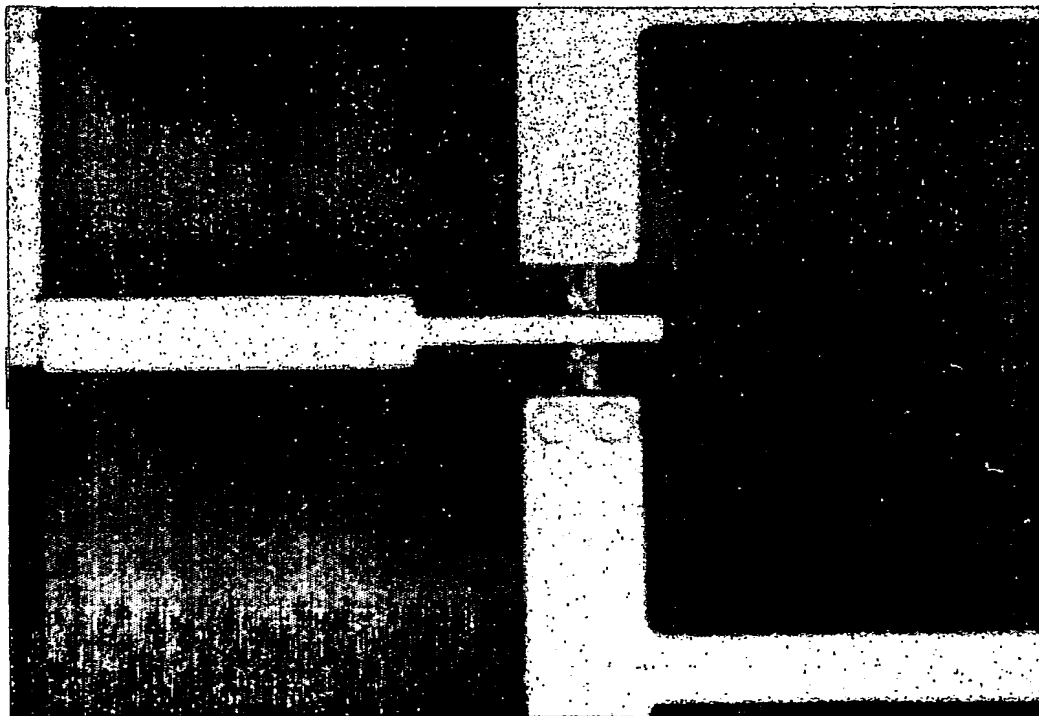


Fig. 10B



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EXPLANATION OF REFERENCE

22: memory cell 24: memory cell 31: word line 32: bit line 33: selection control  
 line 34: resistor element 35: selection transistor 42: memory cell 44: memory  
 5 cell 100: TFT 101: insulating substrate 102: semiconductor film 103: high  
 concentration impurity region 104: channel region 105: gate insulating film 106:  
 gate electrode 107: TFT 108: insulating region 201: word line 202: bit line  
 203: TFT 204: source line 206: TFT 207: TFT 208: TFT 209: TFT 301:  
 semiconductor film 302: electrode 303: insulating substrate 304: high  
 10 concentration impurity region 305: insulating film 306: wiring 307: void 500:  
 substrate 501: peeling layer 502: protective film 503: island shape semiconductor  
 film 504: gate insulating film 505: gate electrode 506: resist 507:  
 P-channel TFT 508: N-channel TFT 509: resist 510: impurity element 511: low  
 concentration impurity region 512: resist 513: impurity element 514: high  
 15 concentration impurity region 601: insulating film 602: resist 603: side wall  
 604: resist 605: impurity element 606: high concentration impurity region 607:  
 interlayer film 608: protective film 609: wiring 701: insulating film 702:  
 insulating film 801: IC tag 802: RF circuit 803: power supply circuit 804:  
 command control circuit 805: clock 806: congestion control circuit 807: memory  
 20 control circuit 808: memory 809: antenna 810: electronic appliance 811:  
 memory 812: CPU 813: I/O controller 814: external device 901: semiconductor  
 film 902: gate electrode 903: insulating substrate 904: high concentration  
 impurity region 905: gate insulating film 906: wiring 907: defect 908:  
 insulating region